

01-807

REMARKS

Claims 1-20 are in the case and claim 20 has been withdrawn from consideration. Claims 1-2, 4-7, 11-17, and 19 are rejected under 35 USC § 102 over USPN 4,237,601 to Woolhouse et al. Claims 3, 8-10, and 18 are rejected under 35 USC § 103 over Woolhouse et al. Claims 1, 14, and 18 have been amended and claims 5-6 and 20 are hereby cancelled. No new matter has been introduced by the amendments, which are supported by the disclosure of the original claims and the specification. Reconsideration and allowance of the claims are requested.

CLAIM REJECTIONS UNDER §102

Claims 1-2, 4-7, 11-17, and 19 are rejected under 35 USC § 102 over Woolhouse et al. Independent claim 1 as amended claims, *inter alia*, forming a feature by laser ablation, where the feature has an upper sidewall portion with an upper sidewall angle, and a lower sidewall portion with a lower sidewall angle, where the upper sidewall angle is shallower than the lower sidewall angle. Woolhouse et al. do not describe such a process. Woolhouse et al. describe separating a substrate into individual devices by first forming channels with a diamond circular saw blade, then etching with an anisotropic etchant solution, and finally mechanically cleaving the substrate into bars of diodes. Woolhouse et al. do not make any description of forming features using laser ablation.

Thus, claim 1 patentably defines over Woolhouse et al. Reconsideration and allowance of claim 1 are respectfully requested. Dependent claims 5-6 are hereby cancelled. Dependent claims 2, 4, 7, and 11-13 depend from independent claim 1, and contain additional important aspects of the invention. Therefore, dependent claims 2, 4, 7, and 11-13 patentably define over Woolhouse et al. Reconsideration and allowance of dependent claims 2, 4, 7, and 11-13 are respectfully requested.

Similar to that as described above in regard to claim 1, independent claim 14 as amended claims, *inter alia*, forming indicia elements by laser ablation, where the indicia elements have an upper sidewall portion with an upper sidewall angle, and a lower sidewall portion with a lower sidewall angle, where the upper sidewall angle is shallower

01-807

than the lower sidewall angle. As detailed above, Woolhouse et al. do not describe such a process.

Thus, claim 14 patentably defines over Woolhouse et al. Reconsideration and allowance of claim 14 are respectfully requested. Dependent claims 15-17 and 19 depend from independent claim 14, and contain additional important aspects of the invention. Therefore, dependent claims 15-17 and 19 patentably define over Woolhouse et al. Reconsideration and allowance of dependent claims 15-17 and 19 are respectfully requested.

CLAIM REJECTIONS UNDER §103

Claims 3, 8-10, and 18 are rejected under 35 USC § 103 over Woolhouse et al. Dependant claims 3 and 8-10 depend from independent claim 1, and therefore claim *inter alia*, forming a feature by laser ablation, where the feature has an upper sidewall portion with an upper sidewall angle, and a lower sidewall portion with a lower sidewall angle, where the upper sidewall angle is shallower than the lower sidewall angle. As detailed above, Woolhouse et al. neither describes such a process, nor makes such a process obvious. Therefore, dependent claims 3 and 8-10 patentably define over Woolhouse et al. Reconsideration and allowance of dependent claims 3 and 8-10 are respectfully requested.

Similar to that as described above, dependant claim 18 depends from independent claim 14, and therefore claims *inter alia*, forming indicia elements by laser ablation, where the indicia elements have an upper sidewall portion with an upper sidewall angle, and a lower sidewall portion with a lower sidewall angle, whcre the upper sidewall angle is shallower than the lower sidewall angle. As detailed above, Woolhouse et al. do not describe such a process. Therefore, dependent claim 18 patentably defines over Woolhouse et al. Reconsideration and allowance of dependent claim 18 are respectfully requested.

CONCLUSION

Applicants assert that the claims of the present application patentably define over the prior art made of record and not relied upon for the same reasons as given above.

01-807

Applicants respectfully submit that a full and complete response to the office action is provided herein, and that the application is now fully in condition for allowance. Action in accordance therewith is respectfully requested.

In the event this response is not timely filed, applicants hereby petition for the appropriate extension of time and request that the fee for the extension be charged to deposit account 12-2355. If other fees are required by this amendment, such as fees for additional claims, such fees may be charged to deposit account 12-2252. Should the examiner require further clarification of the invention, it is requested that he contact the undersigned before issuing the next office action.

Sincerely,

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